ALD 2016 -16th International Conference on Atomic Layer Deposition

Event - ALD 2016 -16th International Conference on Atomic Layer Deposition ↻

Title	ALD 2016 -16th International Conference on Atomic Layer Deposition
When	So, 24. Juli 2016 - Mi, 27. Juli 2016

Description

ALD 2016 -16th International Conference on Atomic Layer Deposition

The 16th International Conference on Atomic Layer Deposition (ALD 2016) will be a three-day meeting dedicated to the science and technology of atomic layer controlled deposition of thin films.This year, the ALD conference will incorporate the Atomic Layer Etching 2016 Workshop, so that delegates at the two events can interact freely. The conference will take place on 24-27 July 2016 at the Convention Centre Dublin, Ireland.

Please find more inforamation relating this event by following link:

http://ald2016.com/

Venue - Dublin

Location	Dublin
City	Dublin
Country	IE